G iant enhancem ent of room -tem perature m agnetoresistance in La_{0:67}Sr_{0:33}M nO ₃/N d_{0:67}Sr_{0:33}M nO ₃ m ultilayers

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Abstract

The m etal-insulator transition temperature in CMR m anganites has been altered and brought close to the room temperature by preparing $La_{0.67}Sr_{0.33}M$ nO₃ (LSMO)/Nd_{0.67}Sr_{0.33}M nO₃ (NSMO) multilayers with ultra thin individual layers of LSMO and NSMO. The LSMO/NSMO multilayers with ultra thin individual layers of about 10A exhibits 150% m agnetoresistance at 270 K whereas LSMO/NSMO multilayers with m oderate individual layer thickness of about 40A each exhibits a mere 15% m agnetoresistance at the same temperature. We have shown that the reduction in thickness of the individual layers leads to increased spin uctuation which results in the enhancem ent of m agnetoresistance.

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Ever since the discovery of colossalm agnetoresistance (CMR) in perovskite m anganites¹, extensive research on the magneotransport properties of manganite Im s, multi-layers, tunnel junctions etc. has been initiated due to its potential for technological applications. The CMR m anganites like $La_{0:67}Sr_{0:33}M nO_3$ (LSM O), $La_{0:67}Ca_{0:33}M nO_3$ (LCM O), $Nd_{0:67}Sr_{0:33}M nO_3$ (NSMO) exhibit transition from a high tem perature param agnetic insulator to a low tem perature ferrom agnetic m etal. In the ground state, these m anganites are fully spin polarized² at the Ferm i level. Encouraged by this high spin polarization, num erous e orts have been m ade to achieve room temperature MR using the extrinsic magnetoresistive properties such as the tunneling magnetoresistance (TMR)² phenomenon observed in manganite tunnel junctions or polycrystalline manganites. However it has been observed that for manganite tunnel junctions, the TMR falls o rapidly with increasing temperature³ and generally vanishes even before reaching the room temperature. Recently large room temperature magnetoresistance has been achieved in magnetic tunnel junctions with M gO as the tunnel barrier and Fe or C oFe as the electrodes^{4,5}. However, in such cases the insulating layer M qO needs to be a highly oriented single crystal, which is very di cult from the fabrication point of view. Moreover, the possibility of the transition metal electrodes having an oxidized and am orphous under-layer cannot be ruled out. Com ing back to the halfm etallic CMR manganites, although such materials produce high intrinsic MR around the Curie tem perature, the fact that their critical tem peratures are wellaway from the room tem perature (for LSM O 360 K; for NSMO T_c 220 K; for LCMO T_c 250 K) com es in the way of obtaining T_c large MR around room tem perature.

We have studied the magneto-transport properties of LSM O /N SM O multi-layers where the thickness of alternate LSM O and N SM O layers have been varied. This study attempts to bring the metal-insulator transition temperature, which is usually nearly coincident with the curie temperature, closer to the room temperature so that large M R can be obtained around the room temperature. We have obtained huge enhancement in magnetoresistance near room temperature by reducing the thickness of alternate layers in LSM O /N SM O magnetic multi-layer.

Four sets of sam ples have been prepared. Sam ple 1 is a LSM 0 lm of thickness 3000A nm; sam ple 2 is a N SM 0 lm of sam e thickness 3000A nm; sam ple 3 is the LSM 0 /N SM 0 m ultilayer with alternate layer thickness 10A [LSM 0 (10A)/N SM 0 (10A)] and sam ple 4 is another LSM 0 /N SM 0 m ultilayer with alternate layer thickness of 40A [LSM 0 (40A)/N SM 0 (40A)] and with LSM O as the top layer. Sample 4 will be used from now on as a reference. The total thickness of all the samples is about 3000A nm each. All the samples were prepared by pulsed laser deposition under identical conditions and deposited on LaA D_3 substrate. X -ray di raction con rm s the epitaxial nature of the samples. The magnetotransport properties were studied using standard four probe method. The magnetic eld was applied parallel to the applied electric eld.

For sample 3, the resistivity curve in absence of magnetic eld (Fig: 1) shows a distinct peak associated with metal-insulator transition at around 280 K. Considering the T_c of bulk LSM O and NSM O, this is a remarkable shift in transition temperature. Sample 1 and sample 4 show more or less the same feature with nometal-insulator transition below 300 K whereas sample 2 exhibits metal insulator transition at 220 K. The absolute value of resisitivities at 3 K in samples 1, 2, 3 and 4 are 46 -cm, 200 -cm, 3950 -cm and 300 -cm, respectively. Since sample 1 and sample 4 exhibit alm ost similar magnetotransport properties and since sample 3 and sample 4 are similar samples with variation in individual layer thickness only, we shall primarily compare the properties of sample 3 with that of sample 4.

The resistivity data was analyzed using a polynom ial expansion in temperature T.W e have tted the resistivity data for sample 3 and 4 with the following function

$$\frac{(T)}{(0)} = 1 + T^2 + T^{4.5}$$

In the present case, the T² term comes from thermal spin uctuation⁶ (of course electronelectron scattering can also give rise to such a term according to Ferm i liquid theory⁷ for system s with high density of states at the ferm i level). The T^{4.5} term perature dependence has been predicted for electron-magnon scattering in the double exchange theory⁸. But the tting is not very satisfactory at very low term perature where the resistivity is almost term perature independent with a very m inor rise with lowering of temperature below 5 K. W e also tried to twith T^{2.5} term instead of T^{4.5} term to include electron-phonon scattering instead of electron magnon scattering but no improvement was observed. Henceforth we excluded the T^{4.5} and T^{2.5} term and the resistivity data was tted considering the function

$$\frac{(T)}{(0)} = 1 + T^2$$

in the tem perature range above 5 K and below approximately $T_{M I}=2$. Most of the studies concerning transport properties of thin lm s of manganites have observed a dominant T^2

term at low tem perature⁹, which is attributed to electron-electron interaction. Chen et. al^{10} have tted the ferrom agnetic m etallic region of the resistivity curve using sm all polaronic transport term $\sinh(C=T)$, C being a constant and a spin wave scattering term $T^{3.5}$. But in our case, the tting is evidently poor when those terms are incorporated. To ascertain whether T^2 term is due to the predom inance of spin uctuations, we tted the resistivity data for sample 3 and 4 with the above polynom ial at di erent m agnetic elds and studied the variation in . The coe cient decreases substantially with increasing m agnetic eld (Fig: 2). This suggests the suppression of spin uctuation by applied m agnetic eld. The observed decrease in with increasing m agnetic eld is m ore pronounced for sam ple 3 in com parison with sam ple 4. This indicates that the reduction in thickness of individual layers has resulted in enhanced spin uctuation in sample 3 com pared to sam ple 4.

The magnetic eld dependence of magnetoresistance (MR) [f (H) (0)g= (H)(%)] for sample 3 and 4 at 3 K shows contrasting behavior in the low and high magnetic eld region (Fig: 4: Inset). In the low magnetic eld region, a sharp drop in resistivity with increasing magnetic eld, associated with the suppression of domain wall scattering, is observed for sample 4 whereas sample 3 shows no low eld magnetoresistance. In the high eld region the MR for sample 4 alm ost saturates, whereas the MR for sample 3 exhibits linear magnetic

eld dependence. However, near the metal insulator transition temperature, enhancement of low eld MR has been observed for sample 3 as compared to sample 4. About 8% MR around 270 K has been observed for sample 3 in a magnetic eld of 5 kO e compared to a mere 1% for sample 4. The comparison of the temperature dependence of high eld MR between sample 1, 3 and 4 is shown in Fig: 3. Enhancement of high eld MR for sample 3 as compared to sample 1 and 4 is observed over the entire temperature range. For sample 3, the MR peaks at 270 K and then decreases with increasing temperature whereas the MR for sample 1 and 4 weakly increases up to 300 K, indicating that both the samples are still well below the ferrom agnetic transition temperature. In contrast to about 15% MR at 270 K for samples 1 and 4, the MR for sample 3 at 270 K is about 150% in 80 kO emagnetic eld. The MR peak at 270 K suggests that the curie temperature is very close to the metal-insulator transition temperature for sample 3 and that the magnetoresistive properties exhibited by sample 3 is purely intrinsic in nature. The temperature dependence of magnetization for sample 3 shows that indeed the curie temperature is at around 270 K (Fig: 3,inset). The separate transition temperatures at about 210 K and 350 K for the NSM O and LSM O layers are evident from the temperature dependence of magnetization for sample 4 (Fig: 3, inset). At 300 K, the MR for sample 3 is about 75% whereas it is only about 25% for samples 1 and 4. We have also studied the magnetic eld dependence of MR for sample 3 and 4 (Fig: 4) at 300 K. While the MR of sample 4 shows linear magnetic eld dependence, the MR for sample 3 shows distinct H^2 dependence up to about 30kO e. This suggests that the origin of enhanced MR in sample 3 is the increased spin uctuation due to reduction in thickness of individual layers and the eventual suppression of spin uctuation by external magnetic eld as already enunciated at the beginning of the discussion.

To summarize, we have compared the magnetotransport properties between the two LSM O /N SM O multi-layers: LSM O (10A)/N SM O (10A) and LSM O (40A)/N SM O (40A), fabricated by us. The magnetotransport properties observed in both the multi-layers do not m in ic the extrinsic inter-granular transport properties shown by ferrom agnetic m etalinsulator composites but are rather intrinsic in nature. A nalyzing the resistivity data in the presence as well as in absence of magnetic eld, we conclude that the reduction in thickness of the individual layers leads to increased spin uctuation in LSM O (10A)/NSM O (10A) and the enhanced magnetoresistance is a consequence of suppression of spin uctuation by applied m agnetic eld. A lthough no extrinsic m agnetoresistive properties due to scattering by dom ain walls or spin polarized tunneling across grain boundaries has been observed, stillenhancem ent of low eld MR has also been achieved over a wide tem perature range near room tem perature for sample 3. At 270 K and 80 kO e m agnetic eld, LSM O (10A)/N SM O (10A)shows 150% magnetoresistance which becomes 75% at 300 K. The enhancement of high eld m agnetoresistance has been observed in LSM O (10A)/NSM O (10A) over the entire tem perature range compared to LSM O (40A)/NSM O (40A) multi-layer and LSM O Im. The results suggest that it is possible to achieve much higher MR around room temperature by tuning the individual layer thickness and exploring suitable m aterials.

- ¹ R.von Helmolt, J.W ecker, B.Holzapfel, L.Schultz, and K.Samwer, Phys.Rev.Lett. 71, 2331 (1993)
- ² M.Viret, M.Drouet, J.Nassar, J.P.Contour, C.Ferm on and A.Fert, Europhys.Lett. 39, 545 (1997)
- ³ J.Z.Sun, D.W. Abraham, K.Roche, S.S.P.Parkin, Appl. Phys. Lett. 73, 1008 (1998)
- ⁴ Shinji Yuasa, Taro Nagahama, Akio Fukushima, Yoshishige Suzuki, and Koji Ando, Nature Materials 3, 868 (2004)
- ⁵ Stuart S. S. Parkin, Christian Kaiser, Alex Panchula, Phillip M. Rice, Brian Hughes, Mahesh Sam ant and See-Hun Yang, Nature Materials 3, 862 (2004)
- ⁶ M oriya T, Jour. M agn. M agn. M ater. 31-34, 10 (1983)
- ⁷ L.D.Landau, Sov.Phys.JETP 3, 920 (1957)
- ⁸ K.Kubo and N.O hata J.Phys.Soc.Jpn.33, 21 (1972)
- ⁹ G.Je rey Snyder, R on Hiskes, Steve DiCarolis, M.R.Beasley, and T.H.Geballe Phys.Rev. B 53, 14434 (1996)
- ¹⁰ X.J.chen, H.-U.Habermeier, C.L.Zhang, and C.C.Almasan Phys. Rev. B 67, 134405 (2003)

FIG.1: Resistivity normalized at 3 K, as a function of temperature, are shown for all the samples. (The absolute values of resistivity at 3 K are mentioned in the text.) The dotted curve corresponds to sample 2, showing the $T_{M I}$ at 220 K; sample 1 and sample 4 show similar temperature dependence of resistivity; whereas $T_{M I}$ for sample 3 is at 280 K, nearabout room temperature.

FIG. 2: The resistivity curves in absence of magnetic eld for samples 3 and 4 have been tted using spin uctuation model, i.e. $\frac{(T)}{(0)} = 1 + T^2$ Variation of with applied magnetic eld for sample 3 and 4 is shown; relative decrease of with applied magnetic eld is greater for sample 3 compared to sample 4. Inset: The T² dependence of resistivity for sample 3 is shown by the continuous line.

FIG. 3: Tem perature dependence of m agnetoresistance at 80 kO e for sam ples 1, 3 and 4. Sam ple 1 and 4 exhibit alm ost identical tem perature dependence. The M R for sam ple 3 at 270 K is about ten times compared to that of sam ple 1 and 4. Inset: Field cooled M vs. T curves at H = 1 kO e for sam ple 3 and sam ple 4.

FIG. 4: Magnetic eld dependence of MR for sample 3 and sample 4 at 300 K.MR shows distinct H² dependence up to 30 kO e for sample 3. Dotted line is the theoretical t. Inset: Magnetoresistance as a function of magnetic eld at 3 K for sample 3 and sample 4. The sm all low eld magnetoresistance for sample 4 is due to suppression of dom ain wall scattering. In contrast, sample 3 shows no low eld magnetoresistance and alm ost linear magnetic eld dependence.

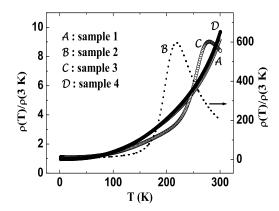


Fig.1

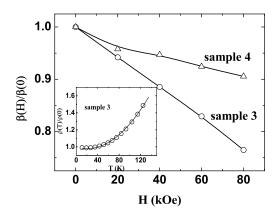


Fig.2

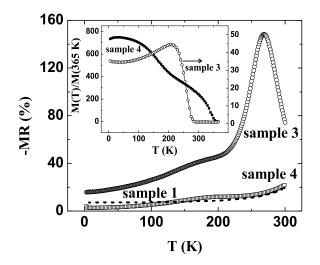


Fig.3

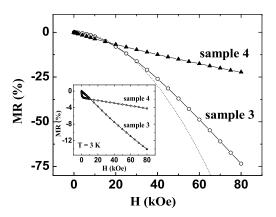


Fig.4